STRAIN-ENHANCED RASHBA SPIN-ORBIT INTERACTION IN CORE-SHELL NANOWIRES

InAs-InP core-shell nanowires

Samuel D. Escribano





The spin-orbit (SO) interaction is a relativistic effect that couples electron momentum and spin

$$H_{SO} = \vec{\alpha} \cdot \left(\vec{\sigma} \times \vec{k}\right)$$

Specially relevant in lowdimensional materials where motion is constrained



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$$H_{CB} = \left(\vec{k}\frac{\hbar^2}{2m^*(\vec{r})}\vec{k} + E_F - e\phi(\vec{r})\right)\sigma_0 + \frac{1}{2}\left(\vec{\alpha}_R(\vec{r}) \cdot \left(\vec{\sigma} \times \vec{k}\right) + \left(\vec{\sigma} \times \vec{k}\right) \times \vec{\alpha}_R(\vec{r})\right)$$

SO interaction

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SO interaction

The Hamiltonian is like the one of a freeelectron with renormalized parameters The SO coupling is Rashba type, origin as a result of the interaction with the hole bands





Theory

We follow exactly the same derivation including a constant strain in the SM using the Bahder approximation

$$H_{\rm CB,s} = \left(\vec{k} \frac{\hbar^2}{2\mathbf{m}_{\rm eff,s}} \vec{k}^t - q_e \phi(\vec{r}) + a_{\rm c} \operatorname{tr} \{\mathbf{e}\}\right) \sigma_0 \\ + \left(\frac{1}{2} \mu_{\rm B} \vec{B} \mathbf{g}_{\rm eff} + \vec{\Omega}_{\rm eff}(\vec{k}, \vec{r})\right) \vec{\sigma}^t$$

With SO field

$$\begin{split} \vec{\Omega}_{\rm eff}(\vec{k},\vec{r}) &= -\frac{P^2}{3} \left(\frac{\frac{1}{2}}{\left(E_{\rm lh}^{(0)}\right)^2} - \frac{\frac{3}{2}}{\left(E_{\rm hh}^{(0)}\right)^2} + \frac{1}{\left(E_{\rm soff}^{(0)}\right)^2} \right) \\ \cdot \operatorname{adj}\left\{ (\mathbf{1} - \mathbf{e}) \right\} \left(\vec{\nabla} \phi(\vec{r}) \times \vec{k} + \vec{k} \times \vec{\nabla} \phi(\vec{r}) \right), \end{split}$$

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The Hamiltonian is very similar. Few remarks:

- SO interaction can no longer be written, in general, through a SO coupling.
- The effective-mass and the gfactor are now tensors with non-diagonal components.
- The strength of all these depend on the strength and type of the strain

One way to control strain, is through a smart choice of the insulating substrates



In stacking planar heterostructures

In core-shell nanowires

We explore experimentally InAs-InP core-shell SM NWs



The strain near the interface is around 5%

Experiments

We perform magnetoconductance measurements to extract the SO coupling



We compare the experimental results with our simulations, looking for the strain that fits the best

$$\alpha_{\rm R} \simeq -\frac{P^2}{3} (1-\varepsilon) \left[\frac{1}{\left(\Delta_{\rm g} + 2\varepsilon \left(a_v - \frac{b}{2}\right)\right)^2} -\frac{1}{\left(\Delta_{\rm g} + \Delta_{\rm soff} + 2\varepsilon a_v\right)^2} \right] E,$$

We perform self-consistent Schrödinger-Poisson simulations

Experiments



The results can only be explained once considered strain! We obtain strain close to 5%

Take home message

- Strain-engineering of the SM material properties is viable.
- We prove SO coupling can be enhanced by proximitizing an insulating SM with different lattice mismatch.
- Our theory predicts intriguing phenomena!



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And thank you for your attention!



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Supplemental material

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Supplemental material - exp

Characterization of its behaviour as a field effect transistor (FET), at room temperature (RT) and 1.7 K

Behaves as expected



Supplemental material - exp

Comparison between the SO coupling in different platforms



Supplemental material - theo

Electric field, SO coupling and charge density of the wire, for two different gate potentials



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Electric field, SO coupling and charge density of the wire, for two different gate potentials